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PATENT APPLICATION
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Kouji FUNAKI, et al.

Appln. No.: 10/024,015

Group Art Unit: 1742

Confirmation No.: 4340

Examiner: Unassigned

Filed: December 21, 2001

For: **SILICON NITRIDE SINTERED MATERIAL AND PRODUCTION PROCESS
THEREOF**

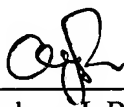
SUBMISSION OF FORMAL DRAWINGS

Commissioner for Patents
Washington, D.C. 20231

Sir:

Submitted herewith please find 1 sheet of formal drawings. The Examiner is respectfully requested to acknowledge receipt of these formal drawings.

Respectfully submitted,



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Date: April 1, 2002

Fig. 1

